

# Optical Remote Sensing - Passive

## Chap. 5. Detector-Sensor Performance (I)

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# 5.1. Detector-sensor architecture overview

## Irradiance at the focal plane

Irradiance due to uniform radiance  $L$  of an area element  $dA_i$  in the aperture

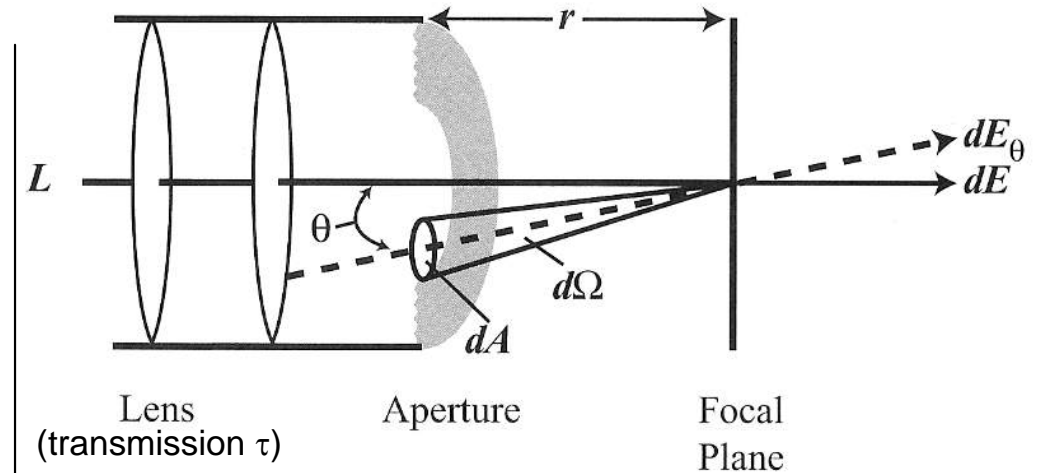
$$dE_i = \tau L d\Omega_i \cos \theta_i$$

where  $d\Omega_i = \frac{dA_i}{r_i^2}$

1) If the aperture is small ( $D \ll f$ , i.e.,  $f\#$  high) then  $\theta_i \approx 0$ ,  $r_i \approx r$ , and

2) If system is focused at infinity,  $r=f$

$$E = \int_A \tau L \frac{dA_i}{f^2} = \dots = \frac{L}{\frac{4(f\#)^2}{\pi\tau}}$$



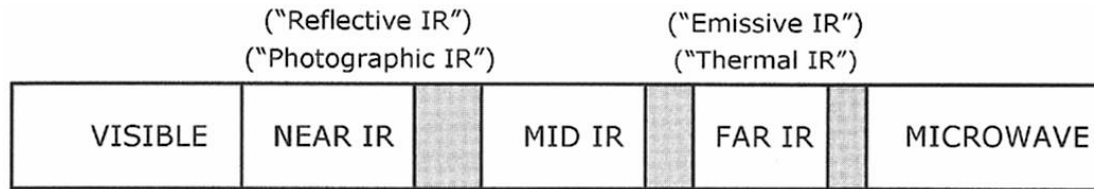
## GENERAL CASE (valid for all $f\#$ )

$G\#$  (throughput of the optical system)

$$E = \frac{L}{G\#} \left[ \frac{W}{m^2} \right]$$

$$G\# = \frac{1 + 4(f\#)^2}{\pi\tau} \left[ sr^{-1} \right], \quad f\# = \frac{f}{D}$$

# Cameras vs. Electro-Optical (EO) imaging systems



0.72  $\mu\text{m}$     1.30  $\mu\text{m}$     3.5  $\mu\text{m}$     4.5  $\mu\text{m}$     8  $\mu\text{m}$     12  $\mu\text{m}$

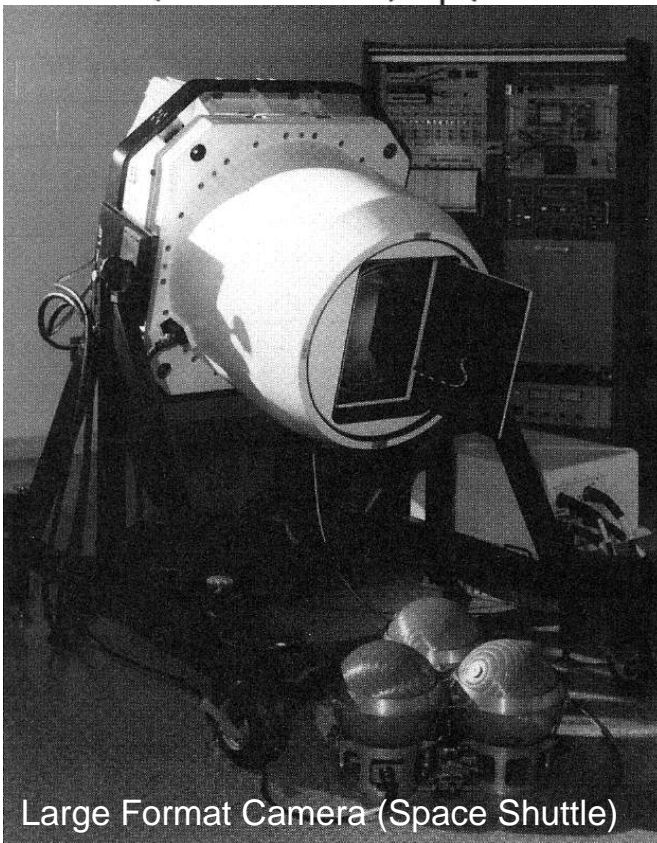
reflected  
sunlight

geothermal  
energy

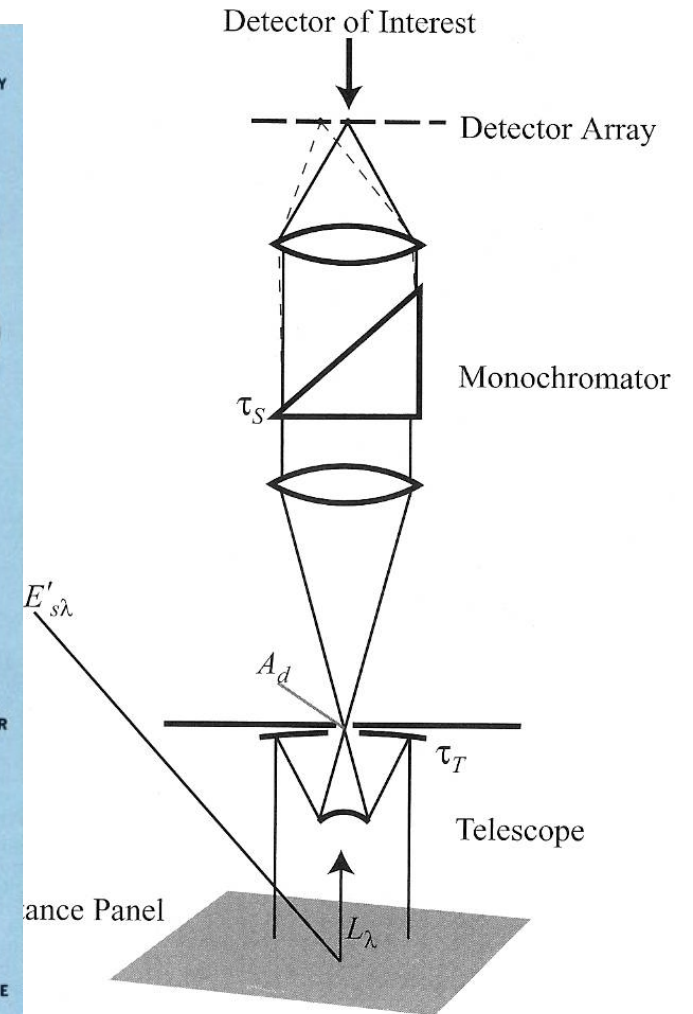
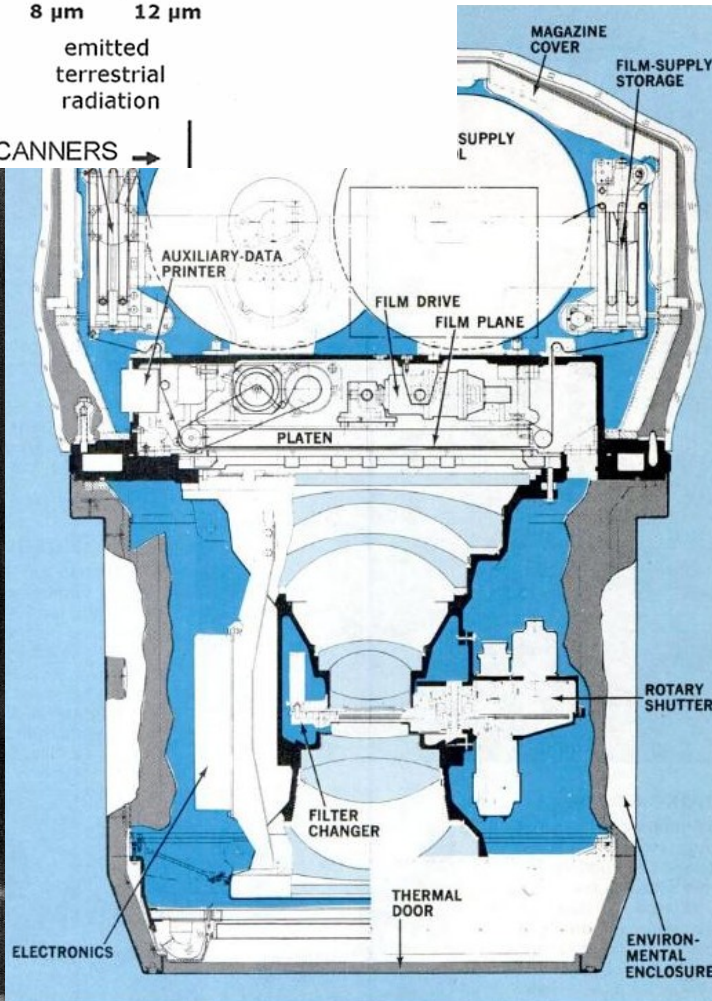
emitted  
terrestrial  
radiation

← CAMERAS →

← THERMAL SCANNERS →



Large Format Camera (Space Shuttle)

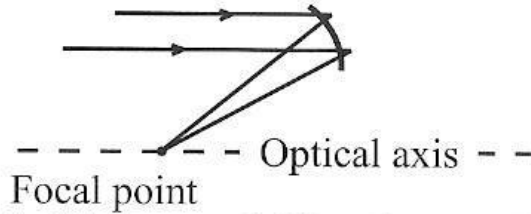


# Optics: Telescope configurations

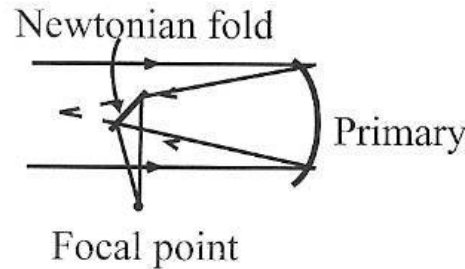
## KEY PARAMETERS:

- Type
- Focal length,  $f$
- Aperture,  $D$
- $f\# = f/D$
- Spectral transmission,  $\tau_T(\lambda)$
- Secondary obscuration,  $D_{obs}$
- Eff. area,

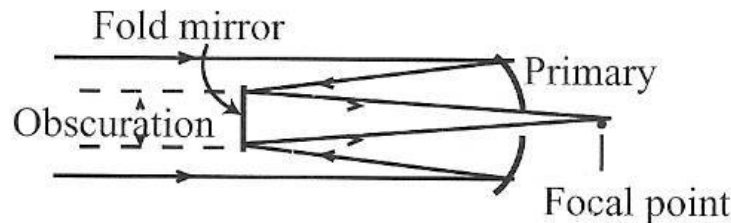
$$A_{ef} = \pi \left( \frac{D}{2} \right)^2 - \pi \left( \frac{D_{obs}}{2} \right)^2$$



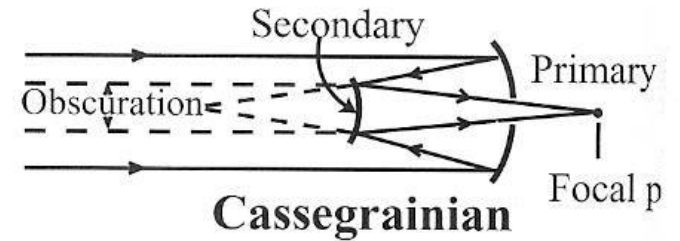
**Herschel Mount (off-axis parabolic)**



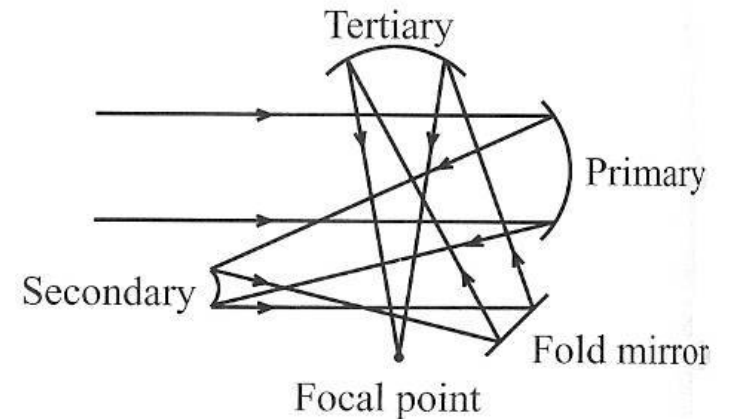
**Newtonian**



**Folded Parabolic**



**Cassegrainian**



**Three-Mirror Anastigmat (TMA)**

# 5.2 Detector types

## I. OVERVIEW OF INFRARED (IR) DETECTORS

| Type         |                           | Detector                         | Spectral response ( $\mu\text{m}$ ) | Operating temperature (K) | $D^*(\text{cm} \cdot \text{Hz}^{1/2} / \text{W})$ |  |  |
|--------------|---------------------------|----------------------------------|-------------------------------------|---------------------------|---|--|--|
| Thermal type | Thermocouple · Thermopile |                                  | Depends on window material          | 300                       | $D^*(\lambda, 10, 1) = 6 \times 10^8$             |  |  |
|              | Bolometer                 |                                  |                                     | 300                       | $D^*(\lambda, 10, 1) = 1 \times 10^8$             |  |  |
|              | Pneumatic cell            | Golay cell, condenser-microphone |                                     | 300                       | $D^*(\lambda, 10, 1) = 1 \times 10^9$             |  |  |
|              | Pyroelectric detector     | PZT, TGS, LiTaO <sup>3</sup>     |                                     | 300                       | $D^*(\lambda, 10, 1) = 2 \times 10^8$             |  |  |
| Quantum type | Intrinsic type            | Photoconductive type             | PbS                                 | 1 to 3.6                  | 300   | $D^*(500, 600, 1) = 1 \times 10^9$     |  |
|              |                           |                                  | PbSe                                | 1.5 to 5.8                | 300   | $D^*(500, 600, 1) = 1 \times 10^8$     |  |
|              |                           |                                  | InSb                                | 2 to 6                    | 213   | $D^*(500, 1200, 1) = 2 \times 10^9$    |  |
|              |                           | Photovoltaic type                | HgCdTe                              | 2 to 16                   | 77  | $D^*(500, 1000, 1) = 2 \times 10^{10}$ |  |
|              |                           |                                  | Ge                                  | 0.8 to 1.8                | 300   | $D^*(\lambda p) = 1 \times 10^{11}$    |  |
|              |                           |                                  | InGaAs                              | 0.7 to 1.7                | 300   | $D^*(\lambda p) = 5 \times 10^{12}$    |  |
|              | Ex. InGaAs                |                                  | 1.2 to 2.55                         | 253                       | $D^*(\lambda p) = 2 \times 10^{11}$               |  |  |
|              | Extrinsic type            |                                  |                                     | InAs                      | 1 to 3.1  | 77                                     | $D^*(500, 1200, 1) = 1 \times 10^{10}$ |
|              |                           |                                  |                                     | InSb                      | 1 to 5.5  | 77                                     | $D^*(500, 1200, 1) = 2 \times 10^{10}$ |
|              |                           |                                  |                                     | HgCdTe → MCT              | 2 to 16   | 77                                     | $D^*(500, 1000, 1) = 1 \times 10^{10}$ |
|              |                           |                                  |                                     | Ge : Au                   | 1 to 10   | 77                                     | $D^*(500, 900, 1) = 1 \times 10^{11}$  |
|              |                           |                                  |                                     | Ge : Hg                   | 2 to 14   |  |  |
|              |                           |                                  |                                     | Ge : Cu                   | 2 to 30   |  |  |
| Ge : Zn      |                           |                                  |                                     | 2 to 40                   |   |  |  |
| Si : Ga      | 1 to 17                   |                                  |                                     |                           |   |  |  |
| Si : As      | 1 to 23                   |                                  |                                     |                           |   |  |  |

| Measurement temperature limit | Infrared detector          |
|-------------------------------|----------------------------|
| 600 °C                        | Si                         |
| 200 °C                        | InGaAs                     |
| 100 °C                        | PbS                        |
| 50 °C                         | PbSe                       |
| 0 °C                          | InSb                       |
| -50 °C                        | MCT, pyroelectric detector |

## I. OVERVIEW OF INFRARED DETECTORS

IR radiation has low energy (e.g., 1.24 eV at 1 $\mu$ m),

$$E = \frac{hc}{q\lambda} = \frac{1.24}{\eta\lambda[\mu\text{m}]} \quad [\text{eV}]$$

### THERMAL DETECTORS (TD):

- Absorb incident flux and undergo a temperature change, which produces a high rate of change in electrical resistance, **R(T)**.
- Photosensitivity is nearly independent of wavelength
- Slow response time (typ. 1 ms)
- Low detection capability
- Do not require cooling
- Used in the MWIR, LWIR

### QUANTUM DETECTORS (QD):

- Photon-matter (photocathode or semiconductor) interaction
  - *quantum efficiency*,  $\eta=[e^-]/[\text{photon}]$
- Photosensitivity is dependent on wavelength
- Faster response speed
- Higher detection performance
- Must be cooled (except in the NIR)
- The noise caused by background fluctuation determines the theoretical limit of  $D^*$  (D star)

## I. OVERVIEW OF INFRARED DETECTORS

### (QD) *EXTRINSIC* or “external photo-effect” detectors:

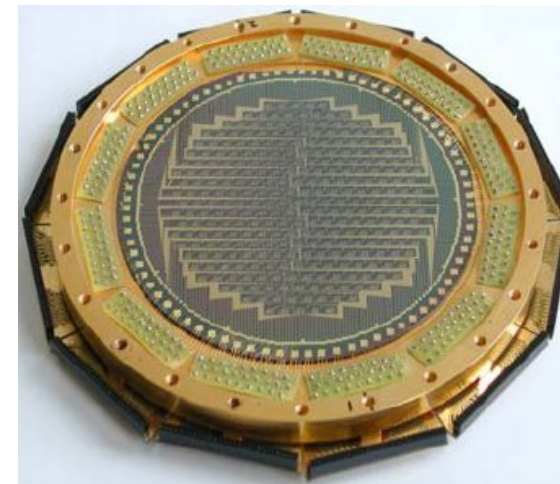
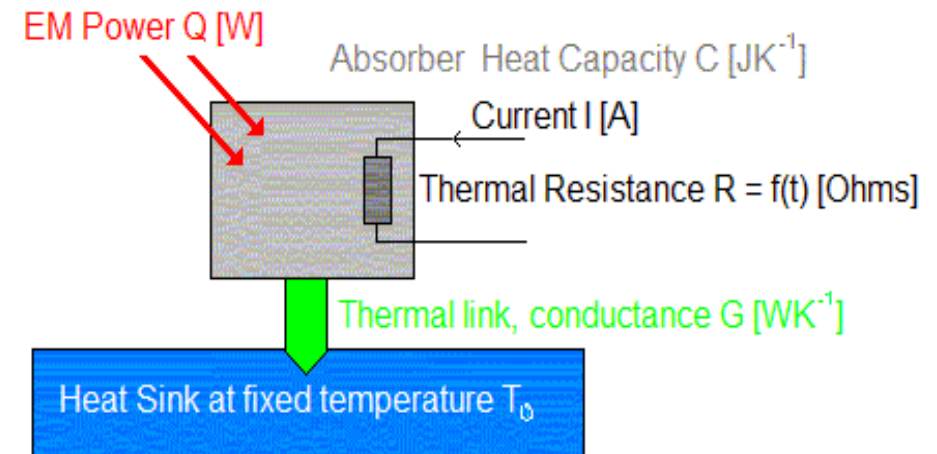
- Photo-sensitive materials (photo-cathodes) with low work functions produce a *current* in an external circuit.
- Limited to VIS-NIR, E.g., **PMT** (Photo Multiplier Tube)

### (QD) *INTRINSIC* or “internal photo-effect” detectors or **PHOTON DETECTORS**:

- Semiconductors in which the electrons undergo internal energy level transitions when they absorb a photon. Most popular covering 0.2-20  $\mu\text{m}$ .
- PHOTOCODUCTIVE (PC) mode:
  - *A reverse bias is applied across the photodiode.*
  - *Wider depletion region, lower junction capacitance, shorter rise time, wider range of light intensities, improved dynamic range*
  - *Shot noise increases due to increased dark current (PIN, APD photodiodes)*
- PHOTOVOLTAIC (PV) mode:
  - *No external bias applied*
  - *Lower dark current  $\rightarrow$  increased sensitivity to low light levels (PIN photodiodes)*

## II. THERMAL DETECTORS: Bolometer

- (S.P. Langley, 1880)
- Device that undergoes changes of resistance as changes in dissipated power occur.
- Consists of an absorptive element (blackened thin layer of metal) connected to a heat sink (a body of constant temperature).
- Types:
  - The *BARRETTTER* ( $R \uparrow$  as dissipated power rises) (metal)
  - The *THERMISTOR* ( $R \downarrow$ ) (SC)
- Metal bolometers work without cooling.
- 1- $\mu\text{m}$  to 2-mm wavelengths



<http://www.apex-telescope.org/bolometer/laboca/technical/>



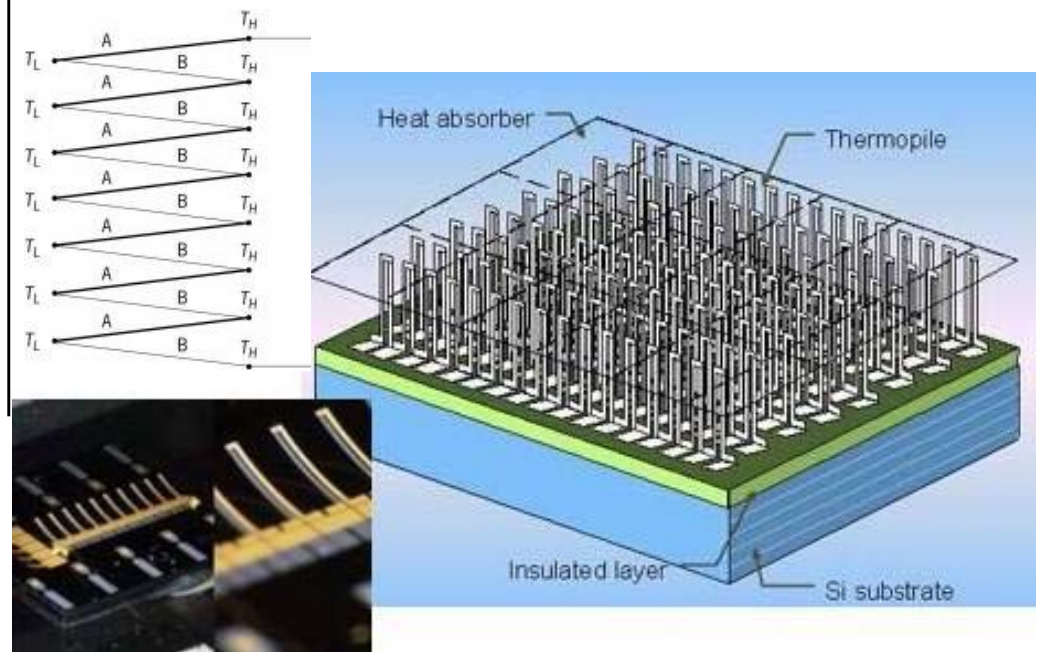
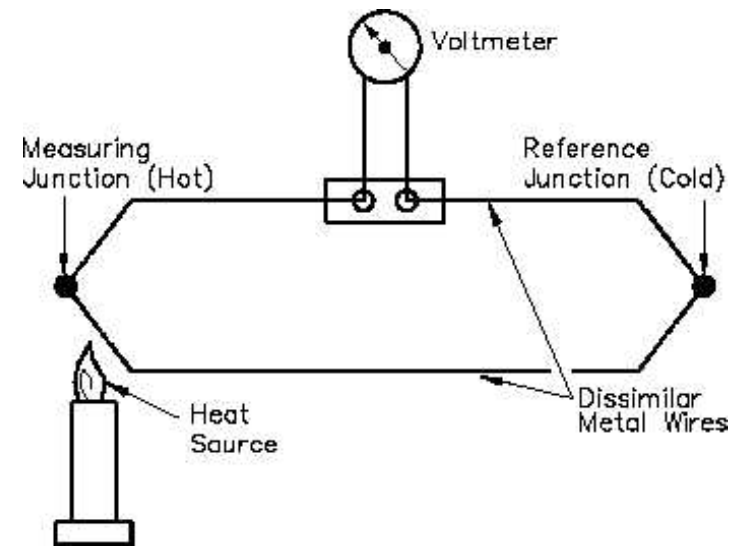
## II. THERMAL DETECTORS: Termocouple/pile

### TERMOCOUPLE

- Any junction of dissimilar metals produces an electric potential related to temperature.
  - Measures Temperature difference (typ.  $1-70 \mu\text{V}/^\circ\text{C}$ )
  - A reference (cold) junction is needed
- (Seebeck's effect, 1821) "any conductor subjected to a thermal gradient generates a voltage".

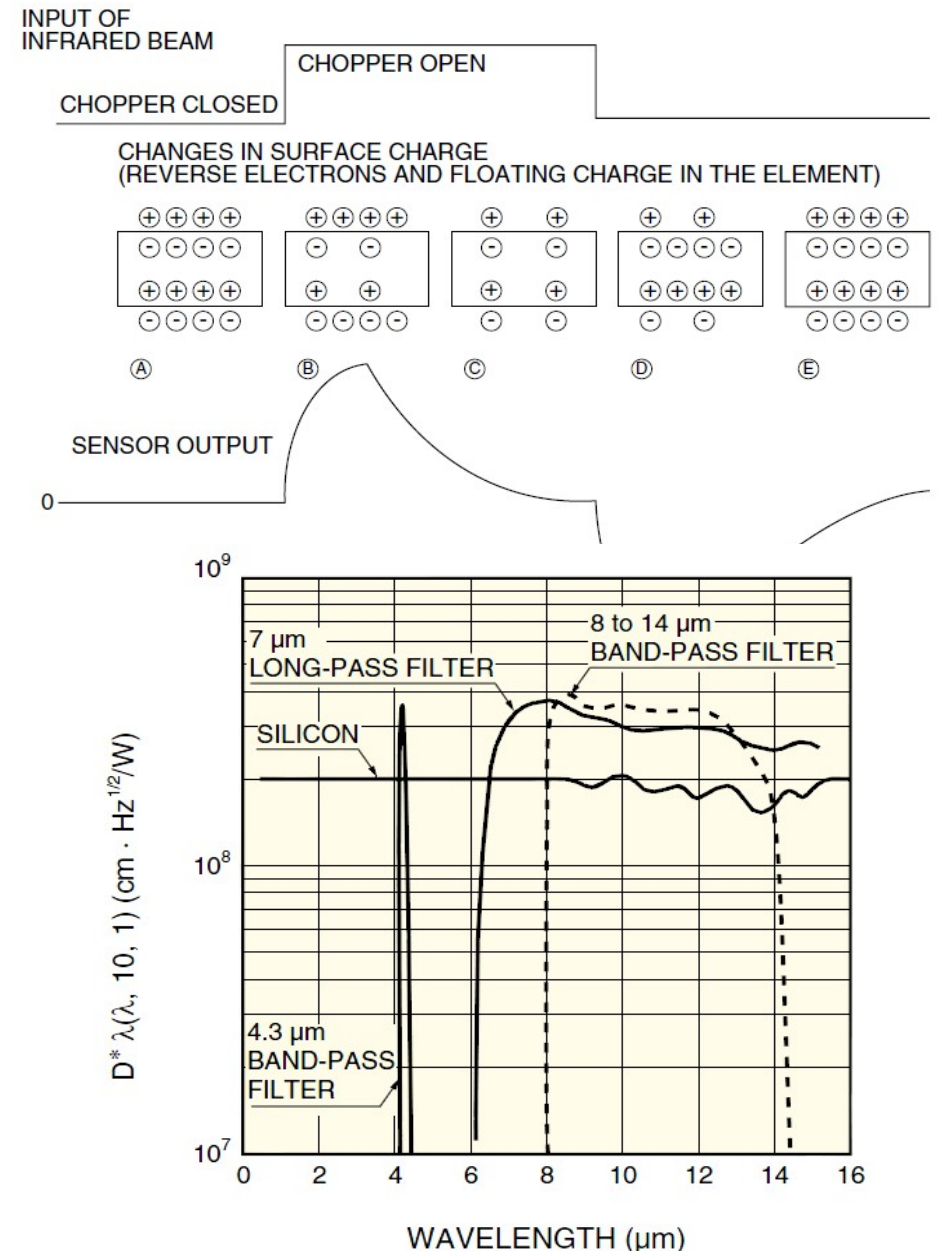
### TERMOPILE

- Converts thermal into electrical energy
- Composed of thermocouples connected usually in series.



## II. THERMAL DETECTORS: Pyroelectric

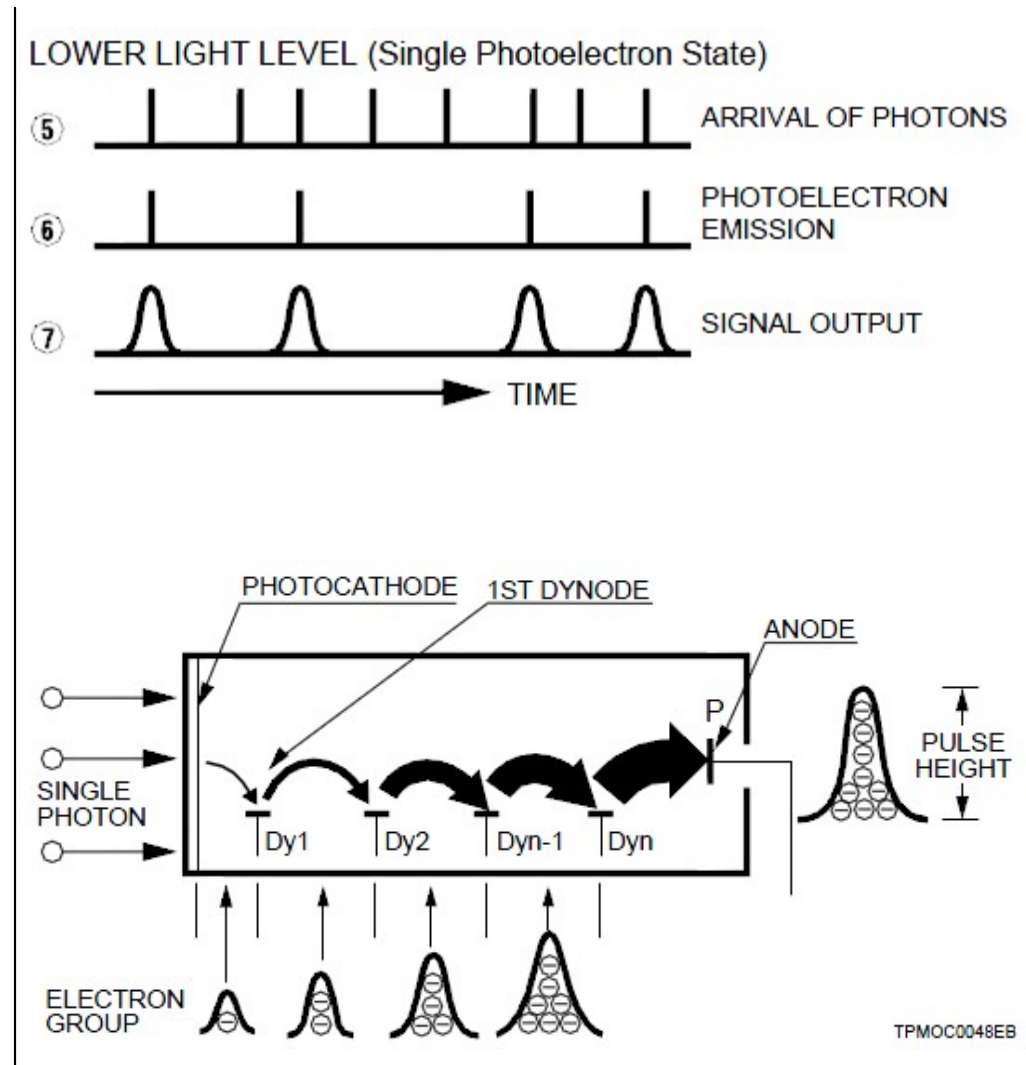
- Consists of a piezoelectric transducer (PZT) having the pyroelectric effect, a high resistor and a low-noise FET.
- When light is absorbed by the PZT, its temperature increases, resulting in a change in the spontaneous polarization state. These changes are output as a voltage *change*.
  - An optical chopper is needed for measurement of still objects
  - No wavelength dependency. Spectral range determined only by the window material used.



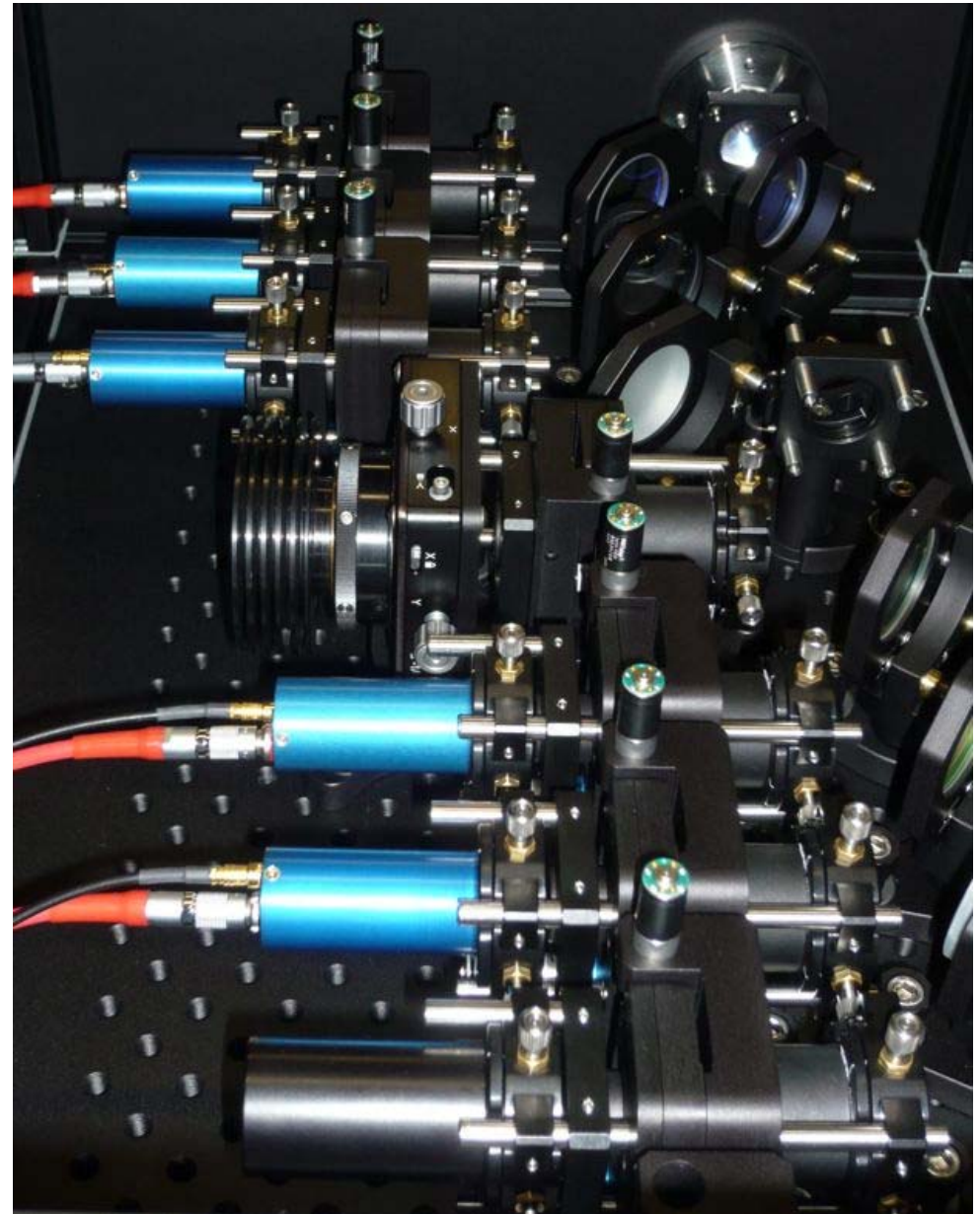
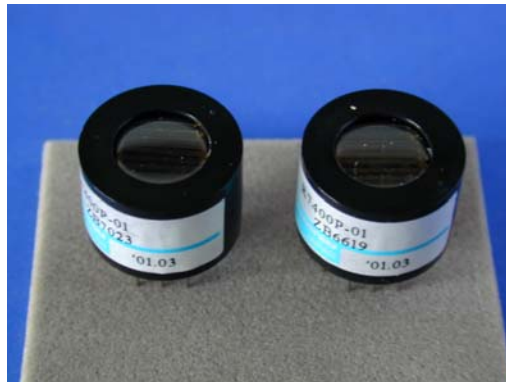
### III. QUANTUM DETECTORS (QD) – EXTRINSIC: Photo Multiplier Tube (PMT)

(Link) *Hamamatsu Application Note* (“Photon Counting”, AN1998) 

- A class of vacuum tubes
- UV, VIS and NIR single-photon detection!
  - *Extremely sensitive*
- PMT structure
  - *Photocathode and dynodes*
- Top characteristics: Very high gain ( $M=10^6-10^8$ ), low noise, high frequency response, large collection area



### III: QD – EXTRINSIC: Photo Multiplier Tube (PMT)



© Source: Wikimedia Commons (ancient PMTs, left column). Hamamatsu Photonics (today's PMTs, left column, bottom right). UPC-RSLAB (UV-VIS-NIR polychromator front end, right column)

## IV. QUANTUM DETECTORS - INTRINSIC: InGaAs PIN photodiode (PV)

### Voltage-current characteristics

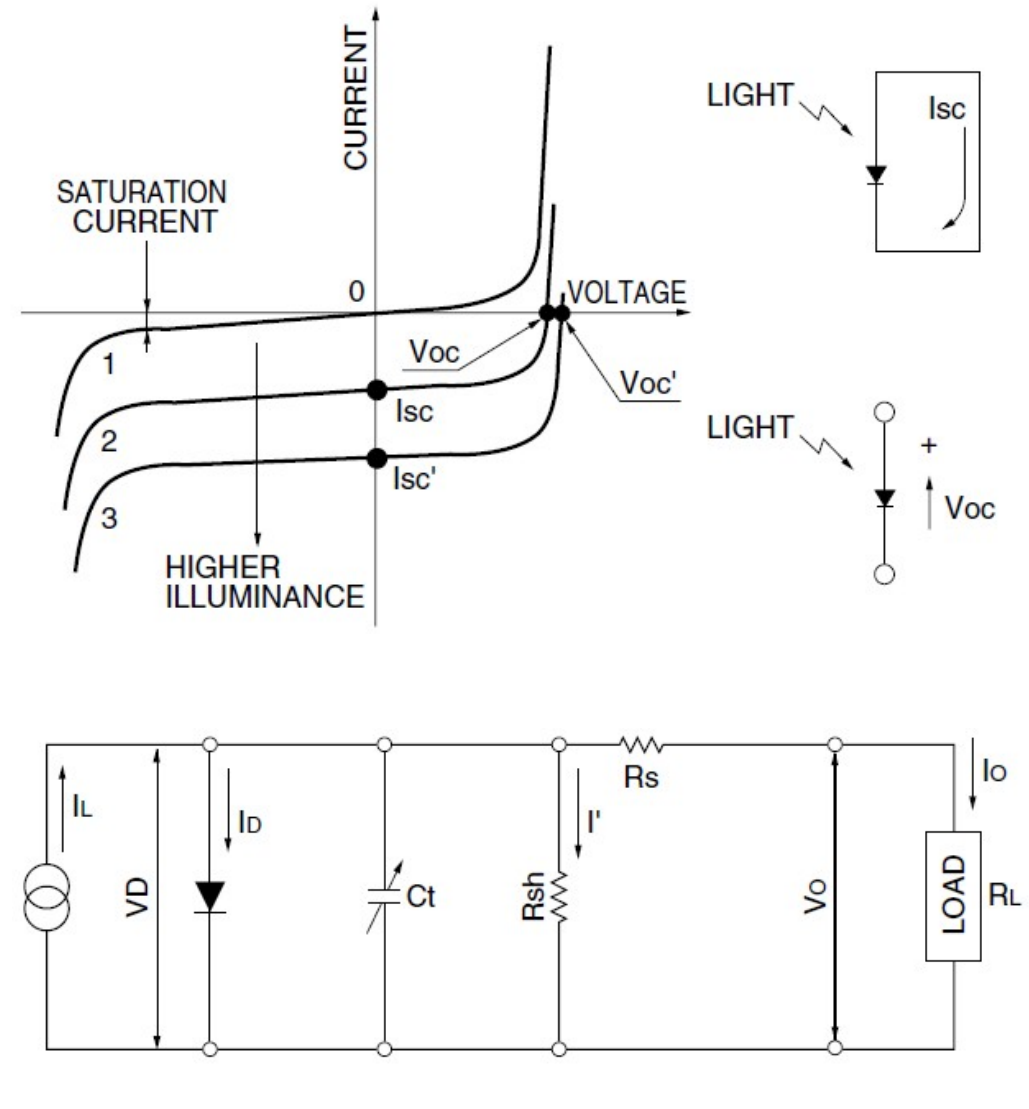
- (Darkness)

$$I_D = I_{sat} \left[ \exp(qV_D/KT) - 1 \right]$$

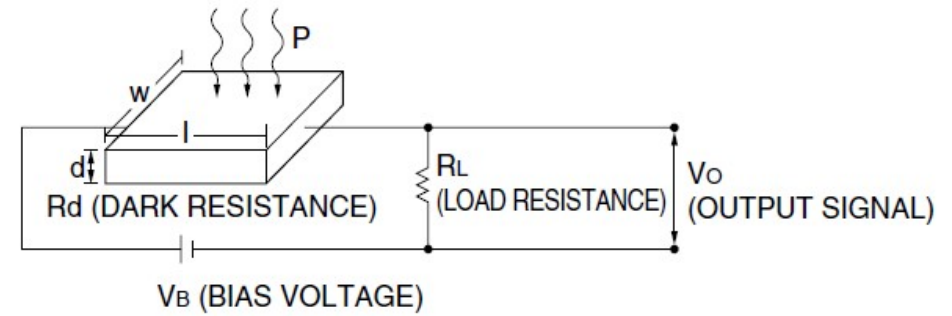
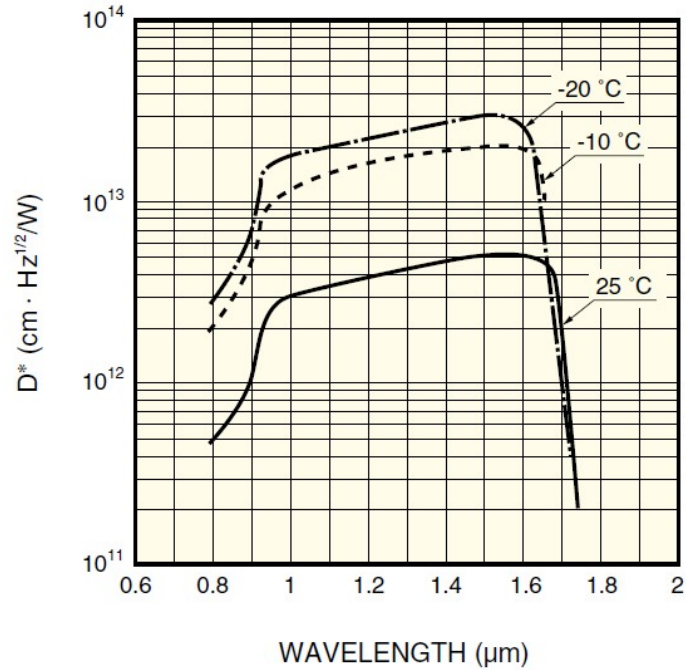
- (Illuminated)

$$I = I_D - I_L, \quad I_L = R_i P$$

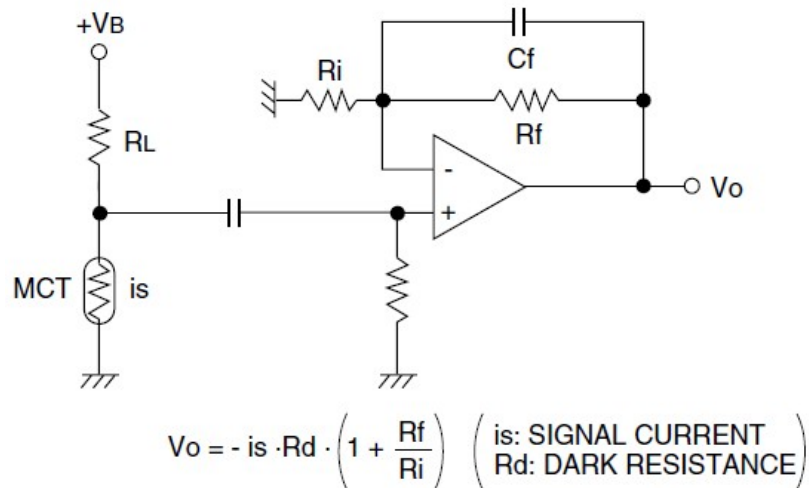
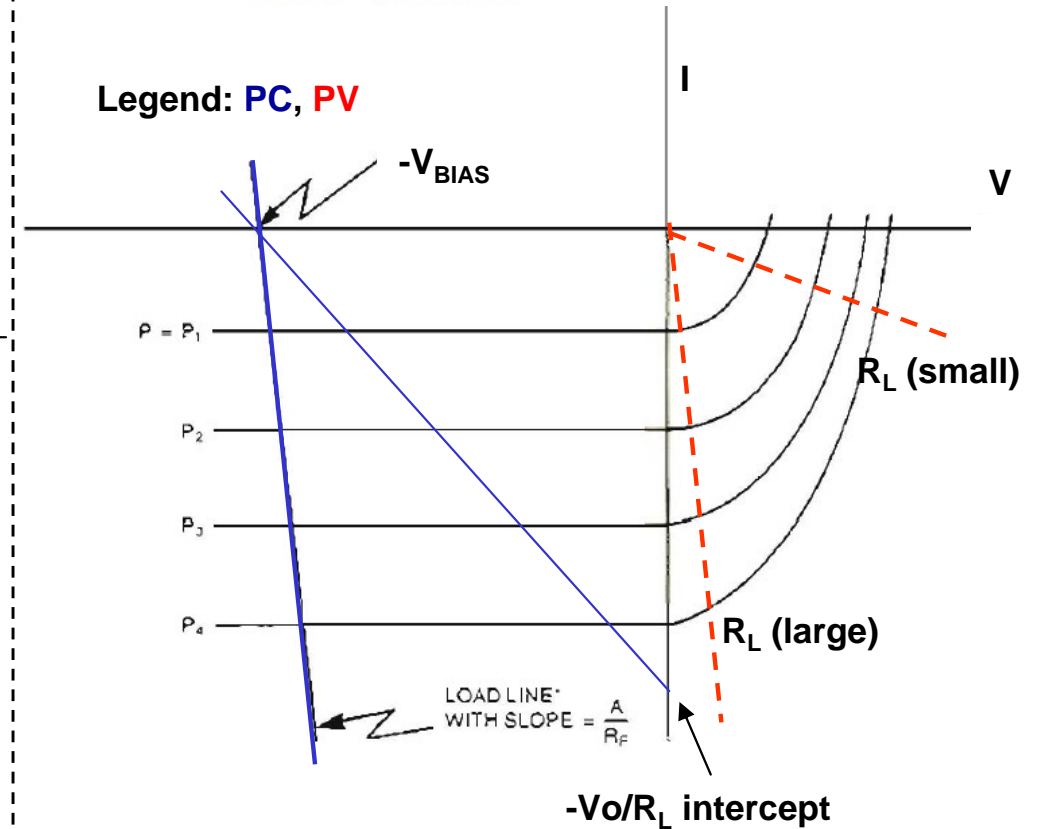
- (Illuminated) When both terminals of the photodiode are left open, a forward voltage  $V_{op}$  appears
- (Illuminated) When both terminals are shorted, a current  $I_{sc}$  flows in the reverse direction
- PC mode also possible (reverse bias applied)



# Photovoltaic (PV) vs. Photoconductive (PC) modes for PIN photodiodes



Legend: **PC**, **PV**

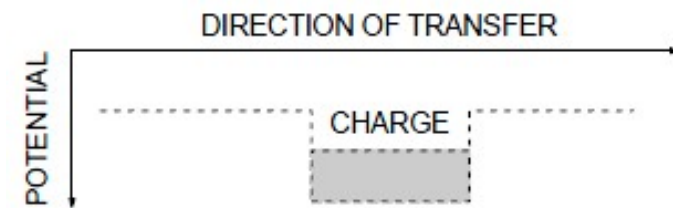
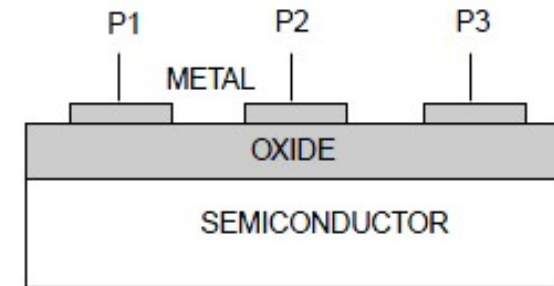


## IV. QD – INTRINSIC: InGaAs CCD arrays

CCD (*Charge-Coupled Device*;  
Boyle-Smith, AT&T Lab., 1970)

Charge that is stored in one area of the CCD is transferred (coupled) to an adjacent area.

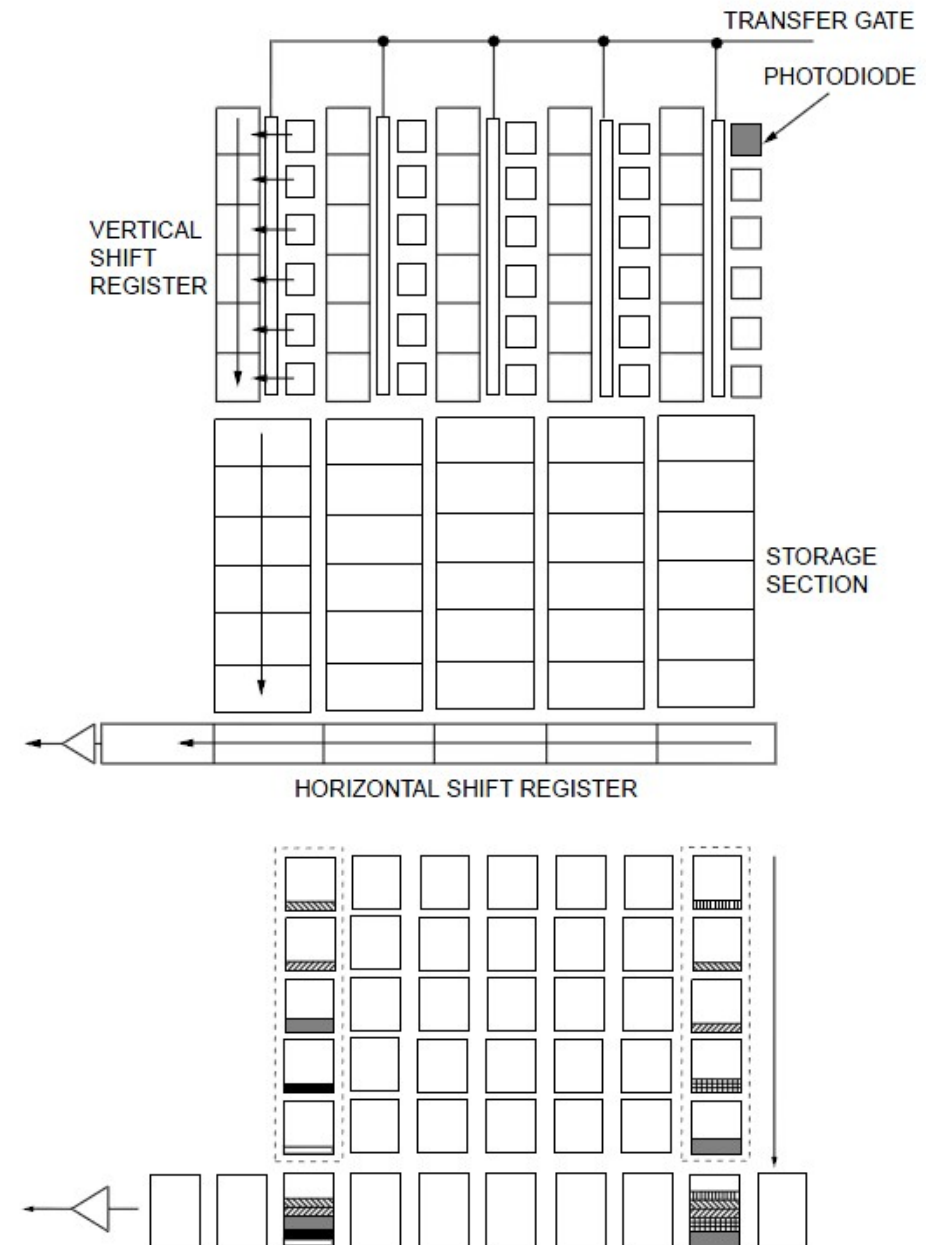
- *Charge-storage areas are referred to as “potential wells”*
- *Based upon a MOS (Metal Oxide Semiconductor) capacitor (Fig.)*
- *Gate electrodes (P1, P2, P3)*
- ***Pixels** are groups of gate electrodes*
- *The CCD is comparable to an “analog” shift register*



- When light comes through transparent electrode into the CCD semiconductor, *photoelectric conversion generates a signal charge that is collected into the **potential well** beneath the electrode.*

## IV. QD – INTRINSIC: InGaAs CCD arrays

- H/V registers
  - The vertical register is series of photosensitive columns (64, 128 or 256 pixels, etc.) which transports charge to the horizontal register.
  - The horizontal register transports charge to an (on-chip) charge-to-voltage amplifier.
  - Two sections: **Photosensitive** section and the **storage** section (the latter can be removed)
- BINNING of signal charge
  - Line and pixel binning are synonyms or charge accumulation (i.e., integration = summation) in potential wells.





## IV. QD – INTRINSIC: InGaAs CCD arrays

### Characteristics

1. *Node sensitivity*: Charge-to-voltage conversion gain,

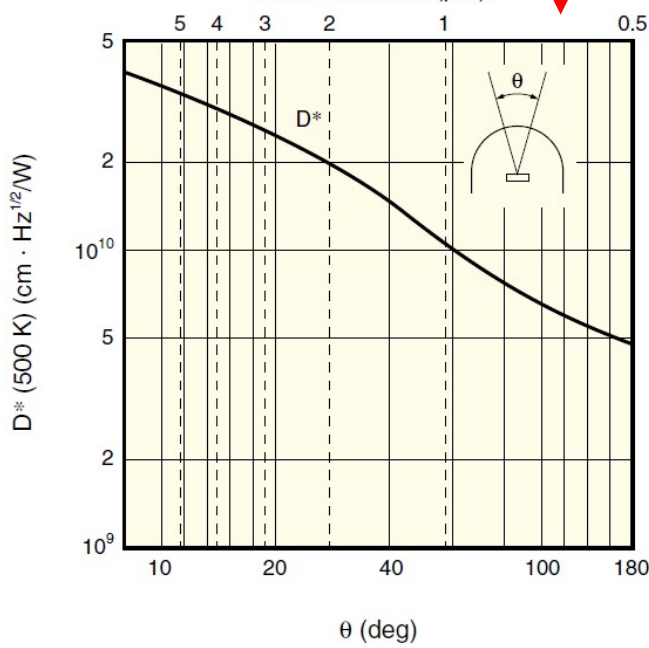
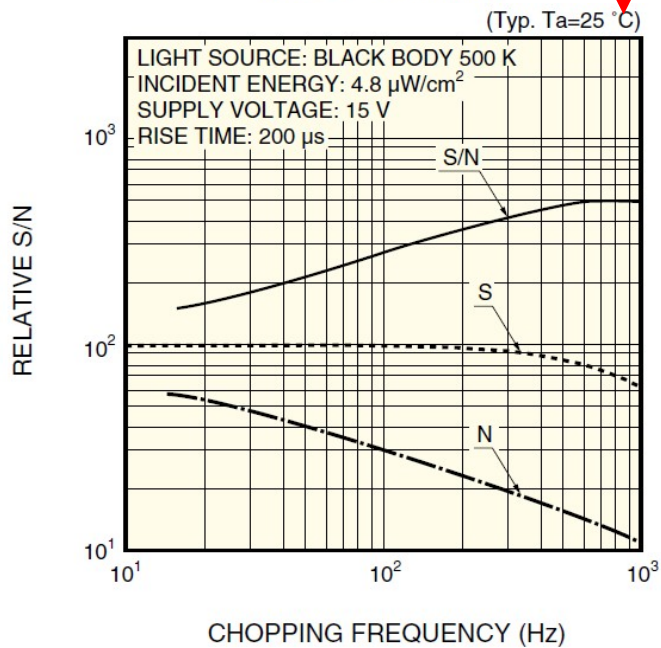
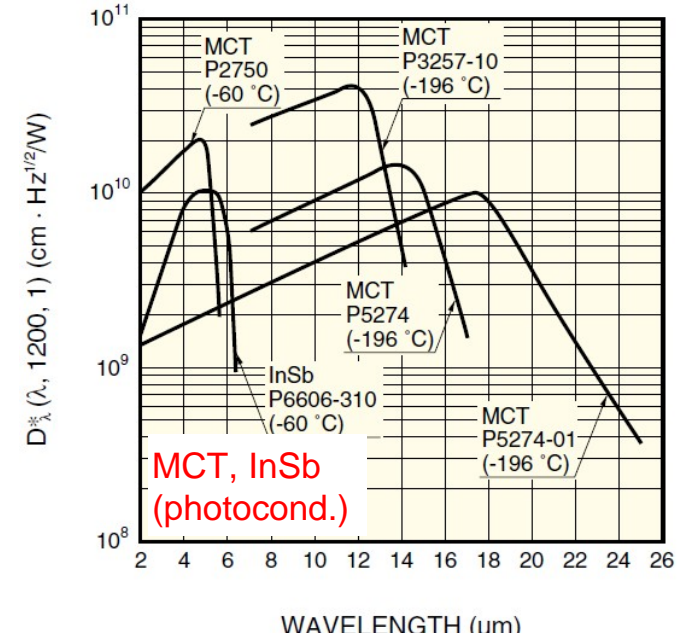
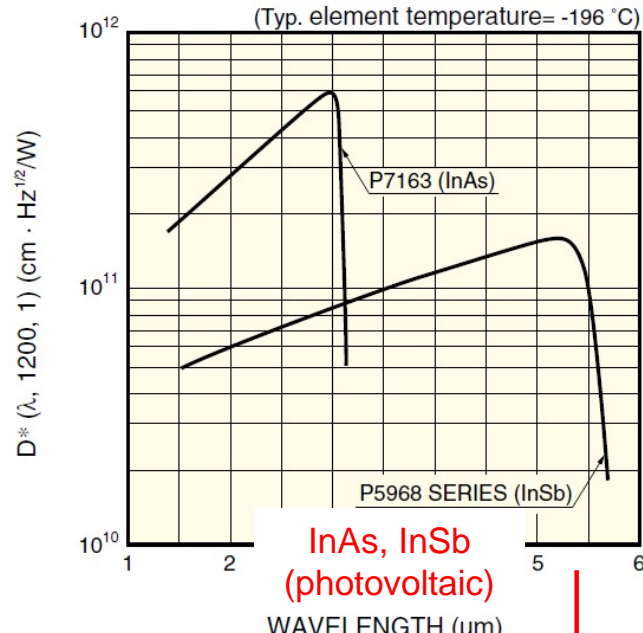
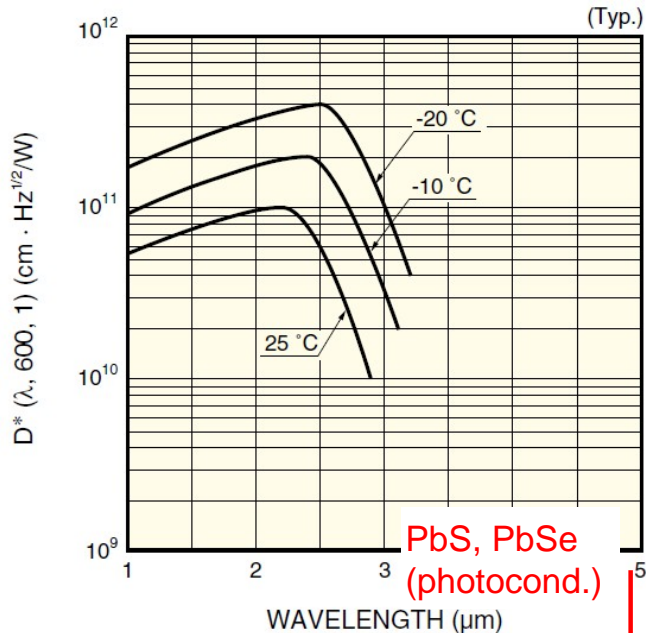
$$S_v = q \frac{\Delta V_{out}}{C_{node}} \left[ \frac{V}{e^-} \right]; \quad \text{with } C_{node} = 44 \text{ fF}, S_v = 2.0 \mu\text{V}/e^-$$

2. *Spectral response*: Determined by the wafer/sensor structure (VIS-NIR)
3. *Photo-Response Non-Uniformity (PRNU)*: Spatial variations in the QE.
4. *Full-well capacity*: Saturation charge for a well.
5. *Charge transfer efficiency* (“bucket brigade fashion”): Typ.  $1-10^{-5}$ .
6. *Dark current*: Expressed as  $\text{A}/\text{cm}^2$  or  $[e^-]/\text{pixel}/\text{s}$
7. *Noise*:
  - Fixed pattern noise (spatial variation in photo-response between neighbouring pixels)
  - Usual noise sources: Photo-induced shot noise, dark-shot noise, and thermal noise.
  - Thermal noise is associated to MOSFET “readout” noise

## IV. QD – Intrinsic Families

FAMILIES: InGaAs (PV) // PbS, PbSe (PC) // InAs, InSb (PV) // MCT, InSb (PC)

Follow ORSP\_IR\_detectors\_summary\_v1.pdf 



## 5.3 Detector figures of merit

RESPONSIVITY (or Photo Sensitivity),  $R$

Wavelength dependent,

$$R(\lambda) = \frac{dS}{d\Phi(\lambda)} \quad \left[ \frac{V \text{ or } A}{W} \right]$$

Effective responsivity,

Notation:

- $R_{io}$  [A/W] (*intrinsic current resp.*)
- $R_i$  [A/W] (*current responsivity*)
- $R_v$  [V/W] (*voltage responsivity*)

$$R = \frac{\int_0^{\infty} R(\lambda)\Phi(\lambda)d\lambda}{\int_0^{\infty} \Phi(\lambda)d\lambda} \quad \left[ \frac{V \text{ or } A}{W} \right]$$

### QUANTUM-TYPE DETECTORS

Intrinsic responsivity (PIN, APD, PMT)

$$\Phi[W] \rightarrow \Phi[W] \frac{1}{\frac{hc}{\lambda}} \left[ \frac{\text{phot}}{s} \right] \eta \left[ \frac{e^-}{\text{phot}} \right] q \left[ \frac{C}{e^-} \right] = \Phi \frac{\eta q \lambda}{hc} [A]; \quad R_{io} = \frac{\eta q \lambda}{hc} \quad \left[ \frac{A}{W} \right]$$

- Therefore,  $R_i = R_{io}M$ ;  $M = 1$  (PIN),  $M \gg 1$  (APD);  $R_v = R_i G_T$ ,  $G_T \left[ \frac{V}{A} \right]$

## 5.3 Detector figures of merit

### SIGNAL, S

- As a rhythm: [V], [A] or [ $e^-/s$ ]
- Over an integration (or “binning”) time,  $\tau_{\text{int}}$ , [counts] (1 [ $e^-$ ] is 1 [count])

### NOISE sources

#### Shot noise:

- Signal-shot photo-induced ( $\sigma_{\text{sh},s}$ ), dark noise ( $\sigma_{\text{sh},d}$ ), *background* ( $\sigma_{\text{sh},\text{back}}$ )  
– POISSON statistics (mean=variance)

#### Thermal (Johnson) noise ( $\sigma_{\text{th}}$ ):

- E.g., preamplifier, load/shunt resistor

*Important to distinguish between the “detector” side and “system-scene” side*

### NOISE, N

- [V], [A], [ $e^-/s$ ], [ $e^-$ ]
- $\sigma_{\text{tot}}$  (noise density) [ $V \cdot \text{Hz}^{-1/2}$ ], [ $A \cdot \text{Hz}^{-1/2}$ ]
- Noise eq. Bandwidth, B [Hz]

$$S = \int R(\lambda) \Phi(\lambda) d\lambda \quad [V \text{ or } A]$$

$$S = \Phi \tau_{\text{int}} \eta \left[ \frac{\text{phot}}{s} \right] [s] \left[ \frac{e^-}{\text{phot}} \right] = [e^-]$$

System Noise example computation:

(1) As a rhythm (rms current, voltage)

$$\sigma_{\text{sh},x} = \sqrt{2qI_x} \left[ \frac{A}{\sqrt{\text{Hz}}} \right]$$

$$\sigma_{\text{tot}} = \left( \underbrace{\sigma_{\text{sh},s}^2 + \sigma_{\text{sh},d}^2}_{\text{non-scene}} + \sigma_{\text{sh},\text{back}}^2 + \sigma_{\text{th}}^2 \right)^{\frac{1}{2}} \left[ \frac{A}{\sqrt{\text{Hz}}} \right]$$

$$N = \sigma_{\text{tot}} \sqrt{B} \quad [A]$$

(2) Over an integration time [ $e^-$ ]

$$N_{\text{sh},s} = \sqrt{S} \quad [e^-]$$

$$N = \left( N_{\text{sh},s}^2 + N_{\text{non-scene}}^2 \right)^{\frac{1}{2}} [e^-]$$

## 5.3 Detector figures of merit

SNR (Signal to Noise Ratio)

$$SNR = \frac{S}{N} \quad [ ]$$

NEP (Noise Equivalent Power)

Convenience to express the noise in radiometric input units [W] rather than in output signal units ([V] or [A]).

$$NEP(\lambda) = \frac{N}{R(\lambda)} \left[ \frac{V \text{ or } A}{\frac{V}{W} \text{ or } \frac{A}{W}} \right] = [W] \quad \text{or} \quad \left[ \frac{W}{\sqrt{Hz}} \right]$$

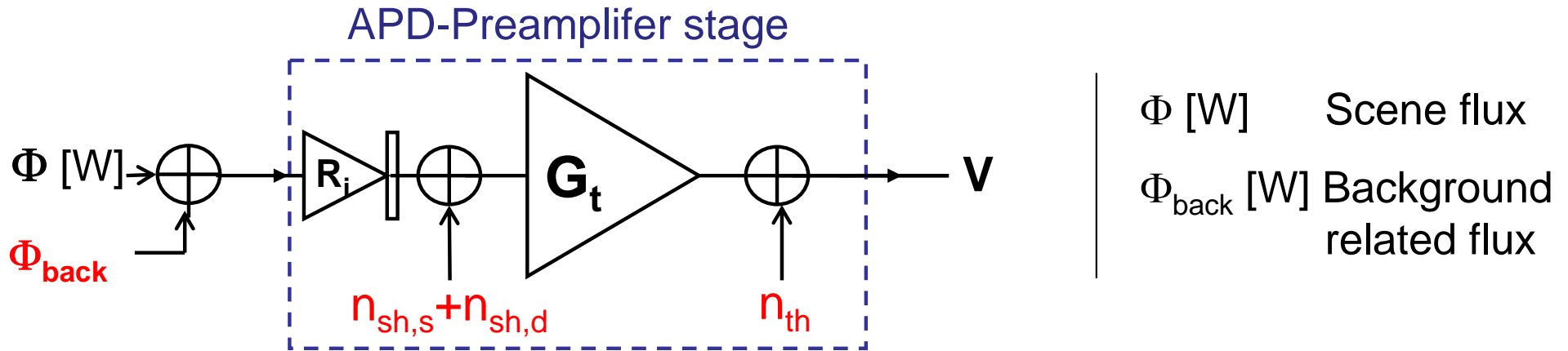
SPECIFIC DETECTIVITY ("D star"),  $D^*$

- Spectral Detectivity,  $D(\lambda)$
- $D^*$  is the spectral detectivity corrected by the area-bandwidth product of the detector
  - *The better the detector the higher  $D^*$*
  - $A_d$  (detector area),  $B$  (bandwidth)

$$D(\lambda) = \frac{1}{NEP(\lambda)} \quad [W^{-1}]$$

$$D^*(\lambda) = \frac{\sqrt{A_d B}}{NEP(\lambda)} \quad [W^{-1} cm \cdot Hz^{1/2}]$$

# Case example: SNR and NEP computation for a NIR reception channel using and APD-preamplifier combination



## NOISE SOURCES

$$\sigma_V^2 = \sigma_{sh,s}^2 + \underbrace{\sigma_{sh,d}^2 + \sigma_{sh,back}^2}_{non-scene (BLIP)} + \sigma_{th}^2 \quad \left[ \frac{V^2}{Hz} \right]$$

$$\sigma_{sh,x}^2 = 2qG_T^2 FM^2 R_{io} \Phi_x, \quad x = "s", "back"$$

photo-induced shot noise

$$\sigma_{sh,d}^2 = 2qG_T^2 (I_{ds} + FM^2 I_{db})$$

dark-shot noise

$$\sigma_{th}^2 = \sigma_{th,i}^2 G_T^2$$

thermal noise

## Case example (CONT.): SNR and NEP computation for a NIR reception channel using and APD-preamplifier combination

### APD PARAMETERS

- Surface + bulk dark current ( $I_{ds}$ ,  $I_{db}$ )
- Multiplication gain,  $M$  [no units]
- Excess-noise factor,  $F \cong M^x$
- $NEP_{APD}$  (manufacturer spec.)

### PREAMP. PARAMETERS

- Transimpedance gain,  $G_T$  [V/A]
- Thermal noise (equivalent input-referred noise density),  $\sigma_{th,i}$  [ $A \cdot Hz^{-1/2}$ ]

### SYSTEM NEP (“sensor NEP”)

**Requires a noise reference:** E.g., Noise associated with viewing a 300K blackbody or a 5% reflector at the TOA.

$$SNR_V = \frac{S}{N} = \frac{\text{useful voltage}}{\text{noise voltage}} = \frac{R_V \Phi}{\sigma_V B^{1/2}}$$

$$NEP_{APD} = \frac{\sigma_{sh,d}^{APD} \sqrt{B}}{R_i^{APD}} = \frac{[2q(I_{ds} + FM^2 I_{db})B]^{1/2}}{\frac{\eta q \lambda}{hc} M} \quad [W]$$

$$NEP = \frac{\sigma_V \sqrt{B}}{R_V} \quad [W]$$



## 5.4 Radiometer relevant parameters (I): Radiometric Sensitivity

Specify SYSTEM (i.e., “sensor”) performance characteristics

### NOISE-EQUIVALENT RADIANCE

Change in radiance on the front of the sensor required to produce a change in the sensor output equal to the sensor’s noise level

- Note: NEP is the “system” NEP

$$NER(\lambda) = \frac{NEP(\lambda)}{A_d} G\# \left[ \frac{W}{m^2 sr} \right]$$

### NOISE-EQ. REFLECTIVITY

$\Delta L/\Delta\rho$ : Rate of change in radiance at the sensor corresponding to a unit change in reflectance

$$NE_{\Delta\rho}(\lambda) = NER(\lambda) \left( \frac{\Delta L}{\Delta\rho} \right)^{-1} [\%]$$

### NOISE-EQ. TEMPERATURE

$$NE_{\Delta T}(\lambda) = NER(\lambda) \left( \frac{\Delta L}{\Delta T} \right)^{-1} [K]$$

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